# organic compounds

Acta Crystallographica Section E **Structure Reports** Online

ISSN 1600-5368

# Trichlorido(N,N'-di-tert-butylbenzamidinato- $\kappa^2 N, N'$ )silicon

### Lu-Dan Lv,<sup>a</sup> Jun-Jun Li,<sup>b</sup> Wei Yang,<sup>a</sup> Chun-Xia Ren<sup>a</sup>\* and Yu-Qiang Ding<sup>a</sup>\*

<sup>a</sup>School of Chemical and Materials Engineering, Jiangnan University, 1800 Lihu Road, Wuxi, Jiangsu Province 214122, People's Republic of China, and <sup>b</sup>College of Pharmacy, GuangDong Pharmaceutical University, Guangzhou, Guangdong Province 510006, People's Republic of China

Correspondence e-mail: chunxiaren@sina.com, liweijun947@163.com

Received 30 March 2008; accepted 15 April 2008

Key indicators: single-crystal X-ray study; T = 273 K; mean  $\sigma$ (C–C) = 0.005 Å; R factor = 0.053; wR factor = 0.160; data-to-parameter ratio = 16.2.

In the title molecule, C<sub>15</sub>H<sub>23</sub>Cl<sub>3</sub>N<sub>2</sub>Si, the Si atom is pentacoordinated by two N atoms [Si-N = 1.780(3)] and 1.931 (3) Å] from the benzamidinate ligand and three chloride anions [Si-Cl = 2.0711 (14)-2.1449 (14) Å] in a distorted trigonal-bipyramidal geometry.

### **Related literature**

For the geometric parameters of related silicon complexes, see: So et al. (2006); Hargittai et al. (1983); Koe et al. (1998); Karsch et al. (1998); Jones et al. (2002).



## **Experimental**

### Crystal data

C <sub>15</sub> H <sub>23</sub> Cl <sub>3</sub> N <sub>2</sub> Si	$\gamma = 84.189 \ (6)^{\circ}$
$M_r = 365.80$	V = 915.3 (7) Å <sup>3</sup>
Triclinic, P1	Z = 2
a = 6.372 (3) Å	Mo $K\alpha$ radiation
b = 10.278 (4) Å	$\mu = 0.56 \text{ mm}^{-1}$
c = 14.229 (6) Å	T = 273 (2) K
$\alpha = 83.222 \ (6)^{\circ}$	$0.35 \times 0.26 \times 0.15 \text{ mm}$
$\beta = 83.227 \ (6)^{\circ}$	

#### Data collection

Bruker SMART CCD area-detector
diffractometer
Absorption correction: none
4535 measured reflections

### Refinement

$R[F^2 > 2\sigma(F^2)] = 0.053$	196 parameters
$wR(F^2) = 0.159$	H-atom parameters constrained
S = 0.99	$\Delta \rho_{\rm max} = 0.44 \text{ e } \text{\AA}^{-3}$
3166 reflections	$\Delta \rho_{\rm min} = -0.43 \text{ e } \text{\AA}^{-3}$

Data collection: SMART (Bruker, 1998); cell refinement: SAINT-Plus (Bruker, 1998); data reduction: SAINT-Plus; program(s) used to solve structure: SHELXS97 (Sheldrick, 2008); program(s) used to refine structure: SHELXL97 (Sheldrick, 2008); molecular graphics: PLATON (Spek, 2003); software used to prepare material for publication: SHELXL97.

3166 independent reflections 2189 reflections with  $I > 2\sigma(I)$ 

 $R_{\rm int} = 0.028$ 

This work was supported by the National Natural Science Foundation of China (grant Nos. 20571033 and 20701016).

Supplementary data and figures for this paper are available from the IUCr electronic archives (Reference: CV2396).

### References

- Bruker, (1998). SMART and SAINT-Plus. Bruker AXS Inc., Madison, Wisconsin, USA.
- Hargittai, I., Schultz, G., Tremmel, J., Kagramanov, N. D., Maltsev, A. K. & Nefedov, O. M. (1983). J. Am. Chem. Soc. 105, 2895-2896.
- Jones, C., Junk, P. C., Leary, S. G., Smithies, N. A. & Steed, J. W. (2002). Inorg. Chem. Commun. 5, 533-536.
- Karsch, H. H., Schlüter, P. A. & Reisky, M. (1998). Eur. J. Inorg. Chem. pp. 433-436
- Koe, J. R., Powell, D. R., Buffy, J. J., Hayase, S. & West, R. (1998). Angew. Chem. Int. Ed. 37, 1441-1442.
- Sheldrick, G. M. (2008). Acta Cryst. A64, 112-122.
- So, C.-W., Roesky, H. W., Magull, J. & Oswald, R. B. (2006). Angew. Chem. Int. Ed. 45. 3948-3950.
- Spek, A. L. (2003). J. Appl. Cryst. 36, 7-13.

# supporting information

Acta Cryst. (2008). E64, o870 [doi:10.1107/S1600536808010398]

# Trichlorido(N,N'-di-tert-butylbenzamidinato- $\kappa^2 N,N'$ )silicon

## Lu-Dan Lv, Jun-Jun Li, Wei Yang, Chun-Xia Ren and Yu-Qiang Ding

### S1. Comment

The discrete electronically neutral mononuclear heteroleptic title silicon(IV) complex, (I), crystallizes in the triclinic space group P-1. The mean plane of Si1/N1/C1/N2 and phenyl ring C2-C7 form a dihedral angle of 79.1 (1) °. The Si-Cl bond lengths lie in the range 2.0711 (14)-2.1449 (14) Å and agree well with those observed in the related silicon complexes (So *et al.*, 2006; Hargittai *et al.*, 1983; Koe *et al.*, 1998). The N1-C1 bond [1.308 (4) Å] is a typical double bond, while C1-N2 bond [1.368 (4) Å] is intermediate between the double and single C-N bonds. The N1-Si1-N2 angle [70.1 (1) °] in (I) is comparable to that in [PhC(NtBu)<sub>2</sub>]SiCl [68.4 (1) °] (So *et al.*, 2006) and in [MeC(Nipr)<sub>2</sub>]<sub>2</sub>SiCl<sub>2</sub> [68.8 (1) and 69.0 (1) °] (Karsch *et al.*, 1998). The Si-N bond lengths of 1.780 (3) and 1.931 (3) Å are slightly longer than the Si—N<sub>amide</sub> bond length in the silicon(IV) complex (C<sub>5</sub>H<sub>3</sub>N-6-Me-2-NSiMe<sub>3</sub>)SiCl<sub>3</sub> [1.753 (5) Å] (Jones *et al.*, 2002).

### S2. Experimental

All manipulations were carried out in an inert atmosphere of  $N_2$  using standard Schlenk techniques and in a  $N_2$  filled glove box. Solvents were dried over and distilled from Na/K alloy prior to use.

PhLi (3.6 ml, 6.48 mmol, 1.8 mol/*L* in cyclohexane/Et<sub>2</sub>O (7:3)) was added to a solution of tBuN=C=NtBu(1.25 ml, 6.48 mmol) in Et<sub>2</sub>O (35 ml) at -78 °C. The solution was raised to ambient temperature and stirred for 1 h. SiCl<sub>4</sub> (0.8 ml, 6.97 mmol) was added to this solution at -78 °C. The resulting yellow suspension was stirred overnight at ambient temperature. The precipitate was filtered, and the filtrate was concentrated under reduced pressure until colourless crystals of the title compound (1.11 g, 46%) were obtained. *M*.p. 178 °C. Elemental analysis (%) calcd for C<sub>15</sub>H<sub>23</sub>Cl<sub>3</sub>N<sub>2</sub>Si: C 49.24, H 6.34, N 7.66; found: C 49.17, H 6.42, N 7.71. <sup>1</sup>H NMR (400 MHz, CDCl<sub>3</sub>, 25 °C):  $\delta$  = 1.18 (s, 18H, tBu), 7.42–7.68 p.p.m. (m, 5H, Ph).

### **S3. Refinement**

The H atoms were positioned geometrically (C—H 0.93–0.97 Å), and allowed to ride on their parent atoms, with  $U_{iso}(H) = 1.2-1.5 U_{eq}(C)$ .



# Figure 1

The molecular structure of (I) showing 30% probability displacement ellipsoids and the atom-numbering scheme. H atoms have been omitted for clarity.

## Trichlorido(N,N'-di-tert-butylbenzamidinato- $\kappa^2 N,N'$ )silicon

Crystal data	
$C_{15}H_{23}Cl_3N_2Si$ $M_r = 365.80$ Triclinic, $P\overline{l}$ a = 6.372 (3) Å b = 10.278 (4) Å	Z = 2 F(000) = 384 $D_x = 1.327 \text{ Mg m}^{-3}$ Mo K\alpha radiation, \lambda = 0.71073 \mathcal{A} Cell parameters from 1365 reflections
c = 14.229 (6)  Å $a = 83.222 (6)^{\circ}$ $\beta = 83.227 (6)^{\circ}$ $\gamma = 84.189 (6)^{\circ}$ $V = 915.3 (7) \text{ Å}^{3}$	$\theta = 2.0-25.0^{\circ}$ $\mu = 0.56 \text{ mm}^{-1}$ T = 273  K Block, colourless $0.35 \times 0.26 \times 0.15 \text{ mm}$
Data collection	
<ul> <li>Bruker SMART CCD area-detector diffractometer</li> <li>Radiation source: fine-focus sealed tube</li> <li>Graphite monochromator</li> <li>φ and ω scans</li> <li>4535 measured reflections</li> <li>3166 independent reflections</li> </ul>	2189 reflections with $I > 2\sigma(I)$ $R_{int} = 0.028$ $\theta_{max} = 25.0^{\circ}, \ \theta_{min} = 2.0^{\circ}$ $h = -7 \rightarrow 7$ $k = -7 \rightarrow 12$ $l = -16 \rightarrow 16$

Refinement

Refinement on $F^2$	Secondary atom site location: difference Fourier
Least-squares matrix: full	map
$R[F^2 > 2\sigma(F^2)] = 0.053$	Hydrogen site location: inferred from
$wR(F^2) = 0.159$	neighbouring sites
S = 0.99	H-atom parameters constrained
3166 reflections	$w = 1/[\sigma^2(F_o^2) + (0.102P)^2]$
196 parameters	where $P = (F_0^2 + 2F_c^2)/3$
0 restraints	$(\Delta/\sigma)_{\rm max} < 0.001$
Primary atom site location: structure-invariant	$\Delta  ho_{ m max} = 0.44 \ { m e} \ { m \AA}^{-3}$
direct methods	$\Delta \rho_{\rm min} = -0.43 \text{ e} \text{ Å}^{-3}$

### Special details

**Geometry**. All e.s.d.'s (except the e.s.d. in the dihedral angle between two l.s. planes) are estimated using the full covariance matrix. The cell e.s.d.'s are taken into account individually in the estimation of e.s.d.'s in distances, angles and torsion angles; correlations between e.s.d.'s in cell parameters are only used when they are defined by crystal symmetry. An approximate (isotropic) treatment of cell e.s.d.'s is used for estimating e.s.d.'s involving l.s. planes.

**Refinement**. Refinement of  $F^2$  against ALL reflections. The weighted *R*-factor *wR* and goodness of fit *S* are based on  $F^2$ , conventional *R*-factors *R* are based on *F*, with *F* set to zero for negative  $F^2$ . The threshold expression of  $F^2 > \sigma(F^2)$  is used only for calculating *R*-factors(gt) *etc.* and is not relevant to the choice of reflections for refinement. *R*-factors based on  $F^2$  are statistically about twice as large as those based on *F*, and *R*- factors based on ALL data will be even larger.

Fractional atomic coordinates and isotropic or equivalent isotropic displacement parameters  $(A^2)$ 

	x	У	Ζ	$U_{ m iso}*/U_{ m eq}$
Si1	0.38635 (14)	0.09933 (9)	0.76514 (7)	0.0428 (3)
Cl1	0.54115 (17)	-0.02445 (10)	0.66177 (8)	0.0732 (4)
C12	0.22531 (16)	-0.05055 (9)	0.84243 (7)	0.0598 (3)
C13	0.67974 (13)	0.13745 (9)	0.80465 (7)	0.0564 (3)
N1	0.2423 (4)	0.2341 (2)	0.83913 (18)	0.0396 (6)
N2	0.2521 (4)	0.2228 (3)	0.68974 (18)	0.0443 (7)
C1	0.1884 (5)	0.3019 (3)	0.7605 (2)	0.0390 (7)
C2	0.1051 (5)	0.4426 (3)	0.7473 (2)	0.0406 (8)
C3	0.2489 (6)	0.5342 (3)	0.7133 (3)	0.0536 (9)
Н3	0.3908	0.5063	0.6976	0.064*
C4	0.1823 (7)	0.6665 (4)	0.7027 (3)	0.0649 (11)
H4	0.2794	0.7278	0.6807	0.078*
C5	-0.0281 (8)	0.7075 (4)	0.7249 (3)	0.0675 (12)
Н5	-0.0728	0.7967	0.7177	0.081*
C6	-0.1716 (6)	0.6183 (4)	0.7572 (3)	0.0596 (10)
H6	-0.3137	0.6470	0.7716	0.072*
C7	-0.1065 (5)	0.4847 (3)	0.7686 (2)	0.0499 (9)
H7	-0.2046	0.4240	0.7906	0.060*
C8	0.1975 (6)	0.2399 (4)	0.5881 (2)	0.0564 (10)
С9	0.3937 (9)	0.2735 (6)	0.5218 (3)	0.0974 (18)
H9A	0.4331	0.3576	0.5330	0.146*
H9B	0.3638	0.2767	0.4570	0.146*
H9C	0.5081	0.2074	0.5335	0.146*
C10	0.0117 (9)	0.3443 (4)	0.5736 (3)	0.0904 (16)
H10A	-0.1015	0.3288	0.6233	0.136*

H10B	-0.0376	0.3396	0.5130	0.136*
H10C	0.0577	0.4300	0.5755	0.136*
C11	0.1190 (7)	0.1105 (4)	0.5664 (3)	0.0682 (12)
H11A	0.2315	0.0412	0.5708	0.102*
H11B	0.0761	0.1215	0.5032	0.102*
H11C	0.0005	0.0882	0.6115	0.102*
C12	0.2239 (5)	0.2735 (3)	0.9381 (2)	0.0452 (8)
C13	0.3108 (7)	0.1583 (4)	1.0033 (3)	0.0732 (12)
H13A	0.2254	0.0860	1.0053	0.110*
H13B	0.3077	0.1839	1.0662	0.110*
H13C	0.4543	0.1319	0.9796	0.110*
C14	0.3482 (7)	0.3920 (4)	0.9418 (3)	0.0686 (12)
H14A	0.4918	0.3739	0.9145	0.103*
H14B	0.3474	0.4087	1.0068	0.103*
H14C	0.2833	0.4677	0.9064	0.103*
C15	-0.0083 (6)	0.3052 (4)	0.9733 (3)	0.0659 (11)
H15A	-0.0616	0.3854	0.9388	0.099*
H15B	-0.0213	0.3155	1.0400	0.099*
H15C	-0.0884	0.2348	0.9633	0.099*

Atomic displacement parameters  $(Å^2)$ 

	<i>I</i> 711	I /22	I /33	I /12	I /13	<i>L</i> /23
~						
Sil	0.0501 (6)	0.0290 (5)	0.0498 (6)	-0.0020 (4)	-0.0022 (4)	-0.0107 (4)
Cl1	0.0790 (7)	0.0593 (7)	0.0827 (8)	0.0118 (5)	0.0007 (6)	-0.0375 (6)
Cl2	0.0756 (7)	0.0345 (5)	0.0695 (6)	-0.0162 (4)	-0.0042 (5)	-0.0006 (4)
Cl3	0.0471 (5)	0.0533 (6)	0.0713 (6)	-0.0056 (4)	-0.0073 (4)	-0.0152 (5)
N1	0.0508 (15)	0.0308 (15)	0.0374 (15)	0.0031 (12)	-0.0052 (12)	-0.0105 (12)
N2	0.0605 (17)	0.0336 (15)	0.0396 (15)	-0.0012 (13)	-0.0024 (13)	-0.0129 (13)
C1	0.0439 (17)	0.0298 (17)	0.0451 (19)	-0.0076 (14)	-0.0032 (14)	-0.0094 (15)
C2	0.053 (2)	0.0281 (17)	0.0425 (18)	-0.0024 (15)	-0.0092 (15)	-0.0083 (14)
C3	0.064 (2)	0.035 (2)	0.063 (2)	-0.0093 (17)	-0.0059 (18)	-0.0084 (17)
C4	0.087 (3)	0.035 (2)	0.075 (3)	-0.017 (2)	-0.016 (2)	-0.002 (2)
C5	0.101 (3)	0.031 (2)	0.073 (3)	0.005 (2)	-0.029 (2)	-0.0103 (19)
C6	0.065 (2)	0.046 (2)	0.068 (3)	0.0146 (19)	-0.015 (2)	-0.0132 (19)
C7	0.056 (2)	0.0355 (19)	0.060(2)	-0.0060 (16)	-0.0092 (17)	-0.0067 (17)
C8	0.088 (3)	0.045 (2)	0.040(2)	-0.015 (2)	-0.0090 (18)	-0.0070 (17)
C9	0.136 (5)	0.114 (4)	0.049 (3)	-0.065 (4)	0.010 (3)	-0.008 (3)
C10	0.151 (5)	0.064 (3)	0.063 (3)	0.016 (3)	-0.053 (3)	-0.014 (2)
C11	0.087 (3)	0.061 (3)	0.064 (3)	-0.017 (2)	-0.013 (2)	-0.023 (2)
C12	0.055 (2)	0.042 (2)	0.0395 (18)	0.0009 (16)	-0.0067 (15)	-0.0108 (16)
C13	0.105 (3)	0.066 (3)	0.046 (2)	0.022 (2)	-0.020 (2)	-0.009(2)
C14	0.091 (3)	0.068 (3)	0.055 (2)	-0.029(2)	-0.004(2)	-0.025(2)
C15	0.068 (3)	0.078 (3)	0.049 (2)	-0.001 (2)	0.0006 (19)	-0.009 (2)

Geometric parameters (Å, °)

Si1—N2	1.780 (3)	C8—C11	1.544 (5)	
Si1—N1	1.931 (3)	С9—Н9А	0.9600	
Si1—Cl2	2.0711 (14)	С9—Н9В	0.9600	
Si1—Cl3	2.1005 (14)	С9—Н9С	0.9600	
Si1—Cl1	2.1449 (14)	C10—H10A	0.9600	
N1—C1	1.308 (4)	C10—H10B	0.9600	
N1-C12	1.499 (4)	C10—H10C	0.9600	
N2—C1	1.368 (4)	C11—H11A	0.9600	
N2-C8	1.513 (4)	C11—H11B	0.9600	
C1-C2	1 488 (4)	C11—H11C	0.9600	
$C^2 - C^7$	1 383 (5)	C12-C13	1 516 (5)	
$C^2 - C^3$	1.385(5)	C12-C15	1.520 (5)	
$C_3 - C_4$	1.379(5)	C12 - C14	1.527 (5)	
С3—Н3	0.9300	C13—H13A	0.9600	
C4-C5	1 375 (6)	C13—H13B	0.9600	
C4—H4	0.9300	C13—H13C	0.9600	
C5	1 363 (6)	C14—H14A	0.9600	
C5_H5	0.9300	C14 H14B	0.9600	
C6C7	1 390 (5)	C14 H14C	0.9600	
С6—Н6	0.9300	C15H15A	0.9600	
C7 H7	0.9300	C15 H15B	0.9600	
$C_{1}^{2}$	1 518 (6)	C15_H15C	0.9600	
$C_{8}$ $C_{10}$	1.518 (0)	015—11150	0.9000	
63-610	1.551 (0)			
N2—Si1—N1	70.14 (12)	C9—C8—C11	110.8 (3)	
N2—Si1—Cl2	120.61 (11)	C10—C8—C11	105.1 (3)	
N1—Si1—Cl2	94.21 (10)	С8—С9—Н9А	109.5	
N2—Si1—Cl3	118.03 (10)	С8—С9—Н9В	109.5	
N1—Si1—Cl3	90.61 (9)	H9A—C9—H9B	109.5	
Cl2—Si1—Cl3	119.05 (6)	С8—С9—Н9С	109.5	
N2—Si1—Cl1	100.24 (10)	Н9А—С9—Н9С	109.5	
N1—Si1—Cl1	169.82 (10)	H9B—C9—H9C	109.5	
Cl2—Si1—Cl1	93.66 (6)	C8—C10—H10A	109.5	
Cl3—Si1—Cl1	91.20 (6)	C8—C10—H10B	109.5	
C1—N1—C12	129.8 (3)	H10A—C10—H10B	109.5	
C1—N1—Si1	89.35 (19)	C8—C10—H10C	109.5	
C12—N1—Si1	139.8 (2)	H10A—C10—H10C	109.5	
C1—N2—C8	128.9 (3)	H10B—C10—H10C	109.5	
C1—N2—Si1	94.06 (19)	C8—C11—H11A	109.5	
C8—N2—Si1	136.8 (2)	C8—C11—H11B	109.5	
N1—C1—N2	105.9 (3)	H11A—C11—H11B	109.5	
N1—C1—C2	127.5 (3)	C8—C11—H11C	109.5	
N2—C1—C2	126.0 (3)	H11A—C11—H11C	109.5	
N1—C1—Si1	56.34 (16)	H11B—C11—H11C	109.5	
N2—C1—Si1	49.93 (16)	N1—C12—C13	108.6 (3)	
C2—C1—Si1	167.6 (2)	N1—C12—C15	109.8 (3)	
			(-)	

C7—C2—C3	119.5 (3)	C13—C12—C15	107.9 (3)
C7—C2—C1	122.9 (3)	N1-C12-C14	111.2 (3)
C3—C2—C1	117.6 (3)	C13—C12—C14	109.3 (3)
C4—C3—C2	120.2 (4)	C15—C12—C14	110.0 (3)
С4—С3—Н3	119.9	С12—С13—Н13А	109.5
С2—С3—Н3	119.9	С12—С13—Н13В	109.5
C5—C4—C3	119.8 (4)	H13A—C13—H13B	109.5
C5—C4—H4	120.1	С12—С13—Н13С	109.5
C3—C4—H4	120.1	H13A—C13—H13C	109.5
C6—C5—C4	120.5 (4)	H13B—C13—H13C	109.5
С6—С5—Н5	119.7	C12—C14—H14A	109.5
С4—С5—Н5	119.7	C12—C14—H14B	109.5
C5—C6—C7	120.3 (4)	H14A—C14—H14B	109.5
С5—С6—Н6	119.9	C12—C14—H14C	109.5
С7—С6—Н6	119.9	H14A—C14—H14C	109.5
C2—C7—C6	119.6 (3)	H14B—C14—H14C	109.5
С2—С7—Н7	120.2	С12—С15—Н15А	109.5
С6—С7—Н7	120.2	C12—C15—H15B	109.5
N2—C8—C9	109.0 (3)	H15A—C15—H15B	109.5
N2-C8-C10	111.9 (3)	С12—С15—Н15С	109.5
C9—C8—C10	111.4 (4)	H15A—C15—H15C	109.5
N2-C8-C11	108.6 (3)	H15B—C15—H15C	109.5